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1029/Hirose

International Application No. PCT/JP99/05777	International Filing Date October 20, 1999	Priority Date Claimed
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Title of Invention: Solder Coated Material and Method for  
Its Manufacture

Applicant(s): Mitsuo ZEN

Attached are the following items filed pursuant to 35 U.S.C. 371 in the  
United States Designated/Elected Office:

1. [X] This express request to begin national examination procedures  
immediately (35 U.S.C. 371(f)).
2. [X] The U.S. National Fee (35 U.S.C. 371(c)(1)) and other fees as  
follows:

CLAIMS	NUMBER FILED	NUMBER EXTRA	RATE	CALCULATIONS
TOTAL CLAIMS	15 -20=	0	x\$18.00	\$ .00
INDEP CLAIMS	3 -3=	0	x\$80.00	\$ .00
MULTIPLE DEPENDENT CLAIM(S) (if applicable)			+\$270.00	\$ .00
BASIC NATIONAL FEE (37 CFR 1.492(a)(1)-(5)):				
[X] Search report has been prepared by the EPO or the JPO.....\$860.00				
[ ] USPTO was International Preliminary Examining Authority (IPEA).....\$690.00				
[ ] USPTO was International Searching Authority (ISA) but not IPEA.....\$710.00				
[ ] USPTO was neither ISA nor IPEA.....\$1000.00				
[ ] USPTO was IPEA and all claims satisfied provisions of PCT Article 33(1) to (4)...\$100.00				\$ 860.00
////////////////////////////////////				
TOTAL OF ABOVE CALCULATIONS				= \$ 00.00
Reduction by 1/2 for filing by small entity, if ap- plicable.				- \$ 00.00
////////////////////////////////////				
TOTAL NATIONAL FEE				\$ 860.00
Fee for recording the enclosed Assignment				+ \$ 00.00
////////////////////////////////////				
TOTAL FEES ENCLOSED				\$ 860.00

- a. [X] A check in the amount of \$860 is enclosed.

b. ☒ The Commissioner is authorized to charge any additional fees that may be required and to credit any excess payment to Deposit Account No. 50-1079. A duplicate copy of this letter is enclosed.

c. ☐ Please charge my Deposit Account No. 50-1079 in the amount of \$ for the fees listed above. A duplicate copy of this letter is enclosed.

3. A copy of the International Application as filed

a. ☒ is attached.

b. ☐ is not required because the International Application was filed in the United States Receiving Office.

c. ☒ has been transmitted by the International Bureau.

4. ☒ A translation of the International Application into English (35 U.S.C. 371(c)(2)).

Amendments to the claims of the International Application pursuant to PCT Article 19 (35 U.S.C. 371 (c)(3))

☐ are attached.

☐ have been transmitted by the International Bureau.

☐ have not been made; however, the time limit for making such amendments has NOT expired.

☒ were not made and the time limit for making such amendments has expired.

☐ A translation of the amendments to the claims made pursuant to PCT Article 19 (35 U.S.C. 371 (c)(3)).

☐ A translation of the Annexes to the International Preliminary Examination Report issued pursuant to PCT Article 36 (35 U.S.C. 371 (c)(5)).

Other document(s) or information attached:

8. ☐ An oath or declaration of the inventor (35 U.S.C. 371(c)(4)).

9.a. ☒ A Preliminary Amendment.

b. ☐ An Information Disclosure Statement.

c. ☒ An International Search Report.

d. ☐ An International Preliminary Examination Report.

e. ☐ A copy of the published International Application.

10.a. ☐ An Assignment document for recording. A separate cover sheet in compliance with 37 CFR §§3.28 and 3.31 is included.

b. ☐ An Associate Power of Attorney.

11. The items checked above are being transmitted:

a. ☐ before the 18th month publication.

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- b. ☒ after the 18th month publication and before 20 months from the priority date.
- c. ☐ by 30 months and a proper demand for International Preliminary Examination was made by the 19th month from the earliest claimed priority date.

Respectfully submitted,

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Date: June 19, 2001  
1029

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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Mitsuo ZEN

National phase of International Application No.: PCT/JP99/05777

International Filing Date: October 20, 1999

For: SOLDER COATED MATERIAL AND METHOD FOR ITS  
MANUFACTURE

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

IN THE CLAIMS:

Please cancel claims 1 - 15 and replace them with the  
following:

16. (new) A solder coated material comprising a substrate  
comprising a difficult to solder material, an electroplated layer  
of a material having excellent solderability provided on the  
substrate as base plating and having a thickness of 0.5 - 5  
micrometers, and a hot dip solder plating layer provided on the  
electroplated layer and having a thickness of 10 - 50 micrometers.

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17. (new) A solder coated material as claimed in claim 16 wherein the difficult to solder material is an iron-nickel alloy.

18. (new) A solder coated material as claimed in claim 16 wherein the material having excellent solderability is selected from gold, silver, copper, tin, nickel, and solder alloys.

19. (new) A solder coated material as claimed in claim 18 wherein the material having excellent solderability is a tin-silver alloy.

20. (new) A portion to be soldered of an electronic part comprising a substrate comprising a difficult to solder material, an electroplated layer of a material having excellent solderability and having a thickness of 0.5 - 5 micrometers applied as base plating atop the substrate, and a hot dip solder plating layer with a thickness of 10 - 50 micrometers applied atop the electroplated layer.

21. (new) A portion to be soldered of an electronic part as claimed in claim 20 wherein the difficult to solder material is an iron-nickel alloy.

22. (new) A portion to be soldered of an electronic part as claimed in claim 20 wherein the material having excellent solderability is selected from gold, silver, copper, tin, nickel, and solder alloys.

23. (new) A portion to be soldered of an electronic part as claimed in claim 22 wherein the material having excellent solderability is a solder alloy of a tin-silver alloy.

24. (new) A portion to be soldered of an electronic part as claimed in claim 20 wherein the portion to be soldered is a lead frame for an electronic part, a lid of a packaged electronic part, a battery terminal, a shield of a module, or a connector for a surface mounted part.

25. (new) A manufacturing method for a solder coated material comprising electroplating a difficult to solder material with a material having excellent solderability to form an electroplated layer, and then passing the difficult to solder material through a molten solder bath and adhering molten solder to the electroplated layer.

26. (new) A manufacturing method for a solder coated material as claimed in claim 25 including applying ultrasonic waves to the molten solder bath.

27. (new) A manufacturing method for a solder coated material as claimed in claim 25 wherein the difficult to solder material is an iron-nickel alloy.

28. (new) A manufacturing method for a solder coated material as claimed in claim 25 wherein the material having

excellent solderability is selected from gold, silver, copper, tin, nickel, and solder alloys.

29. (new) A manufacturing method for a solder coated material as claimed in claim 25 wherein the molten solder bath is maintained in an inert atmosphere.

30. (new) A manufacturing method for a solder coated material as claimed in claim 25 wherein the molten solder bath in the molten solder is a wave soldering bath.

#### REMARKS

In this amendment, original claims 1 - 15 have been replaced by new claims 16 - 30. The original claims were a translation of Japanese claims. The new claims employ a writing style more typical of United States patent applications (for example, "characterized by" has been changed to "wherein") and delete multiple dependencies so as to reduce filing fees. The changes to the claims are in no way related to issues of patentability.

[illegible]

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1029



## Specification

## SOLDER COATED MATERIAL AND METHOD FOR ITS MANUFACTURE

5     Technical Field

10     This invention relates to a method for coating a difficult to solder material which makes up an electronic part with solder, and to a coated material which is obtained in this manner and to an electronic part, and particularly to a portion to be soldered of an electronic part.

Background Art

15     At the time of joining lead frames for electronic parts and lids and the like of packaged electronic parts, soldering is carried out. At this time, solder is usually supplied from the outside and soldering is carried out.

20     In the past, metal materials which have been used in such electronic parts have been metal materials such as copper and copper alloys to which solder readily adheres. However, copper and copper alloys are expensive, and their mechanical strength is not sufficient, so recently, metal materials other than copper and copper alloys have come to be used. Among such metal materials are Kovar (Fe-29Ni-17Co), Alloy 42 (Fe-42Ni), and the like. These metal materials are less expensive than copper and  
25     copper alloys and also have superior mechanical properties, but they are much inferior with respect to solderability.

       Recently, in the soldering of electronic parts, with the

intention of rationalizing soldering, soldering technology has been developed in which solder is not supplied from the exterior each time, but a somewhat excess amount of solder is adhered in advance to a portion to be soldered, and soldering is carried out only with the excess amount of solder which is adhered in advance. Below, this technology will be referred to as the "preplating method".

Electronic parts to which solder is adhered in advance in this manner and in particular portions thereof to be soldered (such as lids and lead frames) include materials in which plate-shaped solder and a difficult to solder material are attached to each other under pressure by rolling (referred to below as solder clad materials), materials to which solder is adhered by immersing a difficult to solder material in molten solder (referred to below as solder coated materials), and the like, which are formed into products by stamping with a press.

In solder clad materials, complete metallurgical bonding does not occur between the plate-shaped solder and the difficult to solder material, so when a solder clad material undergoes stamping with a press to form a part having a desired shape such as a lead frame or a lid, there are cases in which the plate-shaped solder and the difficult to solder material peel from each other, and the difficult to solder material becomes unable to be wet by solder in some locations at the time of soldering.

Furthermore, even with solder coating of a difficult to solder material, it is desirable to adhere an excess amount of solder, but such a sufficient amount of solder can not be

provided in advance with certainty. In addition, in this case, there is a problem if too large an amount of solder is adhered.

For example, in the case of a lid of a semiconductor package, if too large an amount of solder is supplied, the excess solder drips off, and it can be the cause of a malfunction of the electronic device housed in the interior. Furthermore, in the case of a lead frame, if there is a large amount of solder, short circuits with adjoining lead wires occur, and in the case of a small electronic part which is sealed after soldering, if there is a large amount of solder, its volume becomes large after sealing, so it is necessary to provide a necessary and sufficient amount of solder in advance with certainty.

Herebelow, this invention will be explained using a solder coated material for a lid as an example.

#### Disclosure of the Invention

As already described, difficult to solder metal materials (such as Kovar and Alloy 42, which are referred to below as difficult to solder materials) have recently come to be used even as materials for lids, and it has been found that it is not possible to provide in advance and with certainty a necessary and sufficient amount of solder with respect thereto.

When a solder coated material is obtained by immersing a difficult to solder material in molten solder, it is conceivable to use a highly active flux containing a large amount of a halogen component with respect to a difficult to solder material having poor solderability. However, when performing soldering

with a highly active flux, if even a small amount of flux residue remains after soldering, it corrodes the solder and the difficult to solder material, and a corrosion product is produced, which ends up worsening solderability. For this reason, in a solder coating using a flux, after solder is adhered, it was always necessary to perform complete cleaning. A continuous material is advantageous from the standpoint of productivity when manufacturing a solder coated material, and in general a continuous material is used, but in order to perform complete cleaning, it is necessary to use a large cleaning tank and a large amount of cleaning water, and large expenses are necessary for the initial cost of the cleaning tank and the running costs of the water which is used.

From in the past, it has been known that if ultrasonic waves are applied to molten solder and soldering is carried out therein, soldering can be carried out even without a flux. In soldering with ultrasonic waves, the ultrasonic waves peel off oxides and grime adhering to portions to be soldered by means of strong vibrations, and by exposing a clean metal surface, solder can be completely adhered from a metallurgical standpoint.

When ultrasonic waves were employed when applying molten solder plating to a difficult to solder material such as an iron-nickel compound and plating was attempted, in an experiment performed by the present inventors, adequate soldering with respect to a difficult to solder material was not accomplished no matter how strong the ultrasonic waves which were applied.

Accordingly, an object of the present invention is to

provide a molten solder plating method which is effective and highly economical with respect to difficult to solder materials.

Another object of the present invention is to provide a solder coated material for use in a portion to be soldered of an electronic part such as a lead frame or a lid for a package and a manufacturing method therefor.

Yet another object of the present invention is to provide a portion to be soldered of an electronic part such as a lead frame or a lid for a package.

A material used in the present invention is a difficult to solder material such as an iron-nickel alloy. It is known that even with such a material, plating can be easily applied by electroplating. However, it is not possible to use a large amount of solder when performing electroplating with solder, and a solder plated material which is obtained by electroplating cannot be used in the preplating method.

The present inventors discovered that if a layer of solder plating on a portion to be soldered of an electronic part has a thickness of 10 - 50 micrometers, the preplating method can be effectively carried out. Furthermore, they found that even though the amount of solder can not be made this large by electroplating with solder, a difficult to solder material can be easily plated by electroplating, and if a difficult to solder material is first subjected to preplating with a material having good solderability, solder coating to a thickness of 10 - 50 micrometers can be carried out easily and with certainty by hot dipping.

The present inventors subsequently performed repeated investigations, and they found that by guaranteeing a thickness of 0.5 - 5 micrometers as the thickness of base plating formed by electroplating, at the time of hot dipping, a plating thickness of 10 - 50 micrometers can be obtained easily and with certainty by carrying out hot dipping using existing equipment and under normal conditions, and they thereby completed the present invention.

Accordingly, the present invention is a solder coated material comprising a substrate comprising a difficult to solder material, an electroplated layer of a material having excellent solderability and a thickness of 0.5 - 5 micrometers which is provided on the substrate as base plating, and a hot dip solder plated layer having a thickness of 10 - 50 micrometers which is provided on the electroplated layer.

From a different aspect, the present invention is a manufacturing method for a solder coated material characterized by performing electroplating with a material having excellent solderability on necessary locations of a difficult to solder material, and then passing the difficult to solder material through a molten solder bath while applying ultrasonic waves if necessary and adhering molten solder to the electroplated locations.

In a preferred mode of the present invention, the molten solder bath may be maintained in an inert atmosphere, and the molten solder bath may be a wave soldering bath.

Furthermore, according to a different aspect, the present

invention is a portion to be soldered of an electronic part having an electroplated layer of a material having excellent solderability with a thickness of 0.5 - 5 micrometers applied as base plating atop a substrate comprising a difficult to solder material and a hot dip plated layer of solder with a thickness of 10 - 50 micrometers applied atop the electroplate.

In the present invention, examples of materials to be soldered which can be used as the substrate include iron-nickel alloys.

Examples of the material having excellent solderability are any of gold, silver, copper, tin, nickel, and solder alloys, but preferably it is a solder alloy of a tin-silver alloy.

Examples of a portion to be soldered of an electronic part are lead frames of electronic parts, lids of packaged electronic parts, battery terminals, shields for modules, and connectors for surface mounted parts.

#### Best Mode For Carrying Out the Invention

When carrying out the present invention, a hoop material of a difficult to solder material such as an iron-nickel alloy (such as Kovar or Alloy 42) is first prepared. Here, a "difficult to solder material" means a material having poor solderability compared to copper or a copper alloy, and specifically it includes iron-nickel alloys such as those mentioned above.

According to this invention, a material having excellent solderability is applied by electroplating to a difficult to solder material like that described above as base plating with a

thickness of 0.5 - 5 micrometers. With electroplating, it is possible to carry out base plating in a relatively short length of time and with certainty of only necessary locations by performing masking of unnecessary locations. Therefore, in the case of a difficult to solder material, the excellent effect is obtained that solder coating can be carried out only on the necessary locations even if hot dip plating is carried out immediately thereafter.

As a material for electroplating the difficult to solder material, any material having excellent solderability can be used. Gold, silver, copper, tin, nickel, solder alloys, and the like can be used as the material having good solderability, but gold and silver are expensive, and copper diffuses into the molten solder during solder coating and forms intermetallic compounds of copper and it may end up changing the composition of the solder coating. The solderability of nickel becomes extremely poor when it is alloyed with iron, but nickel by itself has good solderability. However, it has inferior solderability compared to tin and solder alloys. Accordingly, as a material for electroplating in the present invention, tin and solder alloys are preferred. However, when tin is applied by electroplating as a base layer, if it is left in the atmosphere for a long period of time, its surface ends up oxidizing, so preferably coating with molten solder is promptly carried out after electroplating.

In a coated material according to this invention, if the electroplated layer which is applied as a base layer has a



thickness of less than 0.5 micrometers, it is difficult for the molten solder which is applied atop it to adhere, while if it is thicker than 5 micrometers, the time required for electroplating becomes long, leading to an increase in the costs for electricity and a decrease in productivity.

Hot dipping with solder to a thickness of 10 - 50 micrometers is carried out on a difficult to solder material which was electroplated in this manner to form a base layer.

Namely, the above-described difficult to solder material which was electroplated is continuously immersed in a plating tank containing a molten solder bath, and by adjusting the speed of lifting, i.e., the immersion time, and the temperature, a solder coating of a prescribed thickness can be provided. When applying ultrasonic waves, a prescribed thickness can be obtained by adjusting the length of application, the position, the frequency, and the like.

It is preferable to carry out hot dipping with solder promptly after electroplating, so the hoop material can be continuously supplied without interruption from the electroplating tank to the molten solder hot dipping tank.

If the thickness of the solder layer which is adhered by hot dipping atop the above-described electroplated layer is less than 10 micrometers, the amount of solder at the time of soldering is inadequate, and soldering defects end up occurring. On the other hand, if the thickness is greater than 50 micrometers, not only does the overall thickness end up being non-uniform, but dripping of solder at the time of soldering, short circuits with

neighboring portions, and an increase in the volume of small sealed parts occur. Preferably, the thickness is 15 - 40 micrometers.

In the present invention, the type of solder alloy which is adhered atop the electroplated layer is a Sn-Pb alloy, or is one having Sn-Pb, Sn, or Pb as a main component to which Ag, Sb, Bi, Cu, In, Ni, Ge, P or the like may be suitably added.

According to a preferred mode of the present invention, hot dipping with solder is carried out by applying ultrasonic waves at the time of hot dipping with solder.

The fluxing action used in soldering (1) removes oxides and grime adhered to a portion to be soldered, (2) promotes wetting and spreading of molten solder, and (3) prevents re-oxidation of a portion to be soldered. Ultrasonic waves have the above-described (1) effect of removing oxides and grime and (2) promoting wetting and spreading, but they do not have (3) the effect of preventing re-oxidation.

Accordingly, if soldering, i.e., solder coating using ultrasonic waves is carried out in the atmosphere, even if solder adheres to the portion to be soldered, the problem develops that oxides adhere to the periphery of the portion to be soldered and solder does not uniformly adhere. In such a case in which oxides adhere to the portion to be soldered, the surface of the molten solder may be covered by an inert atmosphere such as nitrogen or carbon dioxide gas or the like.

A molten solder bath in which the difficult to solder material is immersed may be in a state in which it is not moving

at all, i.e., in a still state, but if the molten solder is put into a spouting state in which it is transported under pressure by a pump and jetted from a nozzle, the molten solder can physically promote the removal of surface oxides and grime from the difficult to solder material which was cleaned by ultrasonic waves, and solderability is further improved.

When performing electroplating of a difficult to solder material and performing solder coating in molten solder according to the present invention, the difficult to solder material may be a short material or a continuous material or have any other shape, but if it is made a continuous material, electroplating and coating in the molten solder bath can be carried out continuously, and in addition, at the time of forming a product, it can be continuously formed into a prescribed shape, so productivity is improved.

According to another mode of the present invention, a material having excellent solderability is applied in advance by electroplating only to necessary locations on a difficult to solder material, and then the difficult to solder material is passed through a molten solder bath to which ultrasonic waves are applied, molten solder is adhered only to the locations which were electroplated as described above, and a portion to be soldered of an electronic part such as a lid of a package or a lead frame is formed.

In this manner, according to the present invention, if a solder layer having a thickness of 10 - 50 micrometers is adhered in advance to a portion to be soldered of an electronic part, not

only is the necessity of separately supplying solder at the time of soldering done away with, but there is no formation of bridges in which solder straddles adjoining portions to be soldered, even with minute portions to be soldered.

5 In the present invention, portions to be soldered of an electronic part to which solder is adhered in advance are lead frames of electronic parts, lids of packaged electronic parts, battery terminals, shields of modules, connectors of surface mounted parts, and other connecting portions for connecting the  
10 electronic parts to other parts.

#### Examples

15 In this example, a continuous iron-nickel alloy plate (Kovar) with a width of 10 millimeters and a thickness of 0.1 millimeters was used as a difficult to plate material. Masking was applied to one surface of the iron-nickel alloy plate, and under usual conditions, a 90Sn-Pb alloy solder as base plating was applied to the other surface to a thickness of 2 micrometers to form an electroplated layer. Subsequently, the continuous  
20 material of the iron-nickel alloy was passed through molten solder (Pb-4Sn-1Ag-1In-8Bi) in a wave soldering tank to which ultrasonic waves were applied. At this time, the molten solder tank had a bath temperature of 340°C and was placed in its entirety in an inert atmosphere filled with nitrogen gas. When  
25 the difficult to solder material was passed at a speed of 5 meters per minute through the wave soldering tank to which ultrasonic waves were applied, solder coating to a thickness of

30 micrometers was carried out only on the locations where electroplating had been performed. The duration of stay in the solder tank was 2 seconds.

5 x 5 mm pieces of the solder coated material which was obtained in this manner were punched out with a press, and lids for semiconductor packages were formed. Then, each lid was mounted on a package, and when heated to 310°C in a nitrogen atmosphere in a reflow furnace without a flux, the package and the lid were completely joined to each other.

5 x 5 mm pieces of a conventional solder clad material in which a Kovar plate and a plate-shaped piece of the above-described solder alloy were joined under pressure were punched out and lids for semiconductor packages were manufactured. There were many instances in which there was peeling of the Kovar and the plate-shaped solder from each other. When a lid which did not undergo peeling and was thought to be a good product was mounted on a package and heating was carried out in a reflow furnace, a large amount of voids (unsoldered portions) in the joint were produced and there was incomplete joining.

#### Possibility of Industrial Use

As explained above, a solder coated material according to this invention has solder which is completely and in an amount necessary for joining adhered to a difficult to solder material, so there is no occurrence of soldering defects at the time of soldering. A method of manufacturing a solder coated material according to the present invention can adequately adhere solder,

even using the hot dip solder plating method, to a difficult to solder material with respect to which it was conventionally thought to be absolutely impossible to adhere solder without the use of flux. Moreover, the electroplate which is the base plating can be applied to just a prescribed location, such as to one surface or just to both ends of one surface, and molten solder can be also adhered just to desired locations.

Accordingly, when a solder coated material obtained according to this invention is used in a portion to be soldered of an electronic part, the effects are obtained that a highly reliable product is obtained in which not only is soldering completely carried out but in which there is no deterioration in the performance of an electronic part due to solder being adhered to unnecessary locations during soldering or damage to the visual appearance.

## Claims

1. A solder coated material comprising a substrate comprising a difficult to solder material, an electroplated layer of a material having excellent solderability provided on the substrate as base plating and having a thickness of 0.5 - 5 micrometers, and a hot dip solder plating layer provided on the electroplated layer and having a thickness of 10 - 50 micrometers.

2. A solder coated material as claimed in claim 1 characterized in that the difficult to solder material is an iron-nickel alloy.

3. A solder coated material as claimed in claim 1 or claim 2 characterized in that the material having excellent solderability is any one of gold, silver, copper, tin, nickel, and solder alloys.

4. A solder coated material as claimed in claim 3 characterized in that the material having excellent solderability is a tin-silver alloy.

5. A portion to be soldered of an electronic part having an electroplated layer of a material having excellent solderability and having a thickness of 0.5 - 5 micrometers applied as base plating atop a substrate comprising a difficult to solder

material, and a hot dip solder plating layer with a thickness of 10 - 50 micrometers applied atop the electroplated layer.

6. A portion to be soldered of an electronic part as claimed in claim 5 characterized in that the difficult to solder material is an iron-nickel alloy.

7. A portion to be soldered of an electronic part as claimed in claim 5 characterized in that the material having excellent solderability is any one of gold, silver, copper, tin, nickel, and solder alloys.

8. A portion to be soldered of an electronic part as claimed in claim 7 characterized in that the material having excellent solderability is a solder alloy of a tin-silver alloy.

9. A portion to be soldered of an electronic part as claimed in any one of claims 5 - 8 characterized in that the portion to be soldered of an electronic part is a lead frame for an electronic part, a lid of a packaged electronic part, a battery terminal, a shield of a module, or a connector for a surface mounted part.

10. A manufacturing method for a solder coated material characterized by performing electroplating on necessary locations of a difficult to solder material with a material having excellent solderability, and then passing the difficult to solder



material through a molten solder bath and adhering molten solder to the electroplated locations.

11. A manufacturing method for a solder coated material as claimed in claim 10 characterized in that ultrasonic waves are applied to the molten solder bath.

12. A manufacturing method for a solder coated material as claimed in claim 10 characterized in that the difficult to solder material is an iron-nickel alloy.

13. A manufacturing method for a solder coated material as claimed in claim 10 characterized in that the material having excellent solderability is any one of gold, silver, copper, tin, nickel, and solder alloys.

14. A manufacturing method for a solder coated material as claimed in any one of claims 10 - 13 characterized in that the molten solder bath is maintained in an inert atmosphere.

15. A manufacturing method for a solder coated material as claimed in any one of claims 10 - 13 characterized in that the molten solder bath in the molten solder is a molten solder bath which is spouting.

## Abstract

The present invention is a solder coated material having a large amount of solder adhered to a difficult to solder material such as Kovar or Alloy 42 and a method which can adhere a sufficient amount of solder to a difficult to solder material without using flux. An electroplated coating is applied to a portion to be soldered of a difficult to solder material, the difficult to solder material is then passed through molten solder to which ultrasonic waves are applied, and a large amount of solder is adhered only to solder plated portions.



DECLARATION AND POWER OF ATTORNEY

As a below named inventor, I declare that:

My residence, post office address, and citizenship are as stated next to my name.

I believe that I am the original, first and sole inventor (if only one name is listed below) or an original, first, and joint inventor (if plural names are listed below) of the subject matter that is claimed and for which a patent is sought on the invention entitled

SOLDER COATED MATERIAL AND METHOD FOR ITS MANUFACTURE

the specification of which

☐ is attached hereto.

(Check one)

☐ was filed on \_\_\_\_\_ as patent application Serial No. \_\_\_\_\_ and was amended on \_\_\_\_\_ (if any).

☒ was filed on October 20, 1999 as PCT International Application No. PCT/JP99/05777 and was amended under PCT Article 19 on \_\_\_\_\_ (if any).

I have reviewed and understand the contents of the specification identified above, including the claims, as amended by any amendment referred to above.

I acknowledge the duty to disclose information that is material to the examination of the patent application identified above in accordance with 37 CFR §1.56(a).

I claim foreign priority benefits pursuant to 35 U.S.C. §119 of any foreign application(s) for patent or inventor's certificate listed below and have also identified below any foreign application for patent or inventor's certificate having a filing date before that of the application from which priority is claimed:

Prior Foreign Application(s)

Priority Claimed

\_\_\_\_\_  
(Country) (Number) (Day/Month/Year Filed)

Yes \_\_\_\_ No \_\_\_\_

\_\_\_\_\_  
(Country) (Number) (Day/Month/Year Filed)

Yes \_\_\_\_ No \_\_\_\_

I claim the benefit pursuant to 35 U.S.C. §119(e) of any United States provisional application(s) listed below:

\_\_\_\_\_  
Application Serial No. Filing Date

\_\_\_\_\_  
Application Serial No. Filing Date

I claim the benefit pursuant to 35 U.S.C. §120 of any United States patent application(s) listed below and, insofar as the subject matter of each of the claims of this patent application is not disclosed in the prior United States patent application(s) in the manner provided by the first paragraph of 35 U.S.C. §112, I acknowledge the duty to disclose material information as defined in 37 CFR §1.56(a) effective between the filing date of the prior patent application(s) and the national or PCT international filing date of this patent application:

\_\_\_\_\_  
Application Serial No. Filing Date Status (Pat./Pend./Aban.)

\_\_\_\_\_  
Application Serial No. Filing Date Status (Pat./Pend./Aban.)

I appoint:

Michael Tobias, Reg. 32948

my attorney with full power of substitution and revocation to prosecute my application for Letters Patent identified above and to transact all business in the Patent and Trademark Office connected with that patent application.

I authorize my attorney to accept and follow instructions from

S. Hirose and Associates regarding any matter related to the preparation, examination, grant, and maintenance of the application identified above, any continuation, continuation-in-part, or divisional based on the patent application identified above, and any patent issuing from that patent application, until I or my assigns withdraw this authorization in writing.

I direct that correspondence concerning this application be sent to Michael Tobias, Suite 304, 1730 K Street N.W., Washington, D.C. 20006, telephone (301) 587-6541.

I declare that all statements made here based on my own knowledge are true and that all statements made on information and belief are believed to be true, and further that these statements were made with the knowledge that willful, false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful, false statements may jeopardize the validity of the patent application identified above or any patent issuing from the patent application identified above.

Full name of sole or first inventor: Mitsuo ZEN

Inventor's signature Mitsuo Zen

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